

**What is Claimed is:**

1. A phase shift mask, comprising:

a transparent substrate having a trench-type guard  
5 ring pattern for shifting the phase of light transmitted  
therethrough by 180°; and

a half-tone phase shift pattern disposed on the  
transparent substrate and surrounded by the guard ring  
pattern.

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2. The phase shift mask according to claim 1,  
wherein the transparencies of the transparent substrate and  
the guard ring pattern are 100%, respectively.

15 3. The phase shift mask according to claim 1,  
wherein the transparency of the half-tone phase shift  
pattern ranges from 0 to 25%, and the half-tone phase shift  
pattern shifts the phase of light transmitted theretrhough  
by 0° or 180°.

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